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## **Claims**

- Method for the manufacture of a high temperature superconducting layer on a
  substrate (1a, 1b) comprising the following steps:
  - a. deposition of an RBa<sub>2</sub>Cu<sub>3</sub>O<sub>7</sub>-layer (2) onto the substrate (1a, 1b) with a low growth rate, wherein R represents yttrium, an element of the group of rare-earth elements (atomic number 57-71) or mixtures of two or more of these elements;
  - b. deposition of an XBa<sub>2</sub>Cu<sub>3</sub>O<sub>7</sub>-layer (3) onto the RBa<sub>2</sub>Cu<sub>3</sub>O<sub>7</sub>-layer (2) with a high growth rate, wherein X represents yttrium, an element of the group of rare-earth elements (atomic number 57-71) or mixtures of two or more of these elements.
  - 2. Method according to claim 1, wherein the low growth rate is < 1 nm/s and wherein the high growth rate is > 1 nm/s, preferably > 2 nm/s.
- 3. Method according to claim 1 or 2, wherein the RBa<sub>2</sub>Cu<sub>3</sub>O<sub>7</sub>-layer (2) comprises a thickness of < 500 nm, preferably < 100 nm.
  - 4. Method according to one of the claims 1-3, wherein the  $RBa_2Cu_3O_7$ -layer (2) has a thickness of > 5 nm.
  - 5. Method according to one of the claims 1-4, wherein the XBa<sub>2</sub>Cu<sub>3</sub>O<sub>7</sub>-layer (3) has a thickness of  $> 1\mu m$ .

- 6. Method according to one of the claims 1-5, wherein the RBa<sub>2</sub>Cu<sub>3</sub>O<sub>7</sub>-layer (2) is deposited onto an at least biaxially textured substrate (1a) or a substrate with an at least biaxially textured buffer layer (1b).
- 7. Method according to one of the claims 1 6, wherein the XBa<sub>2</sub>Cu<sub>3</sub>O<sub>7</sub>-layer
  (3) is deposited as a precursor layer, comprising the metal components of the high temperature superconducting layer.
- 8. Method according to claim 7, wherein the precursor layer is transformed in a further method step by a temperature treatment with a high transformation rate into a superconducting XBa<sub>2</sub>Cu<sub>3</sub>O<sub>7</sub>-layer (3).
  - 9. Method according to claim 8, wherein the transformation rate is > 2 nm/s.
- 10. Method according to one of the claims 1 9, wherein R represents a rare-earth element with a great ion radius (La, Pr, Nd, Sm, Eu, Gd) or compounds comprising to at least 50% these elements in mixtures with other rare-earth elements
- 11. Layer system of a high temperature superconductor manufactured according to a method of any of the claims 1 10.